

Plans for small gap operation at SLS

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Swiss Light Source

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PSI

ICFA 17th Advanced Beam Dynamics Workshop on

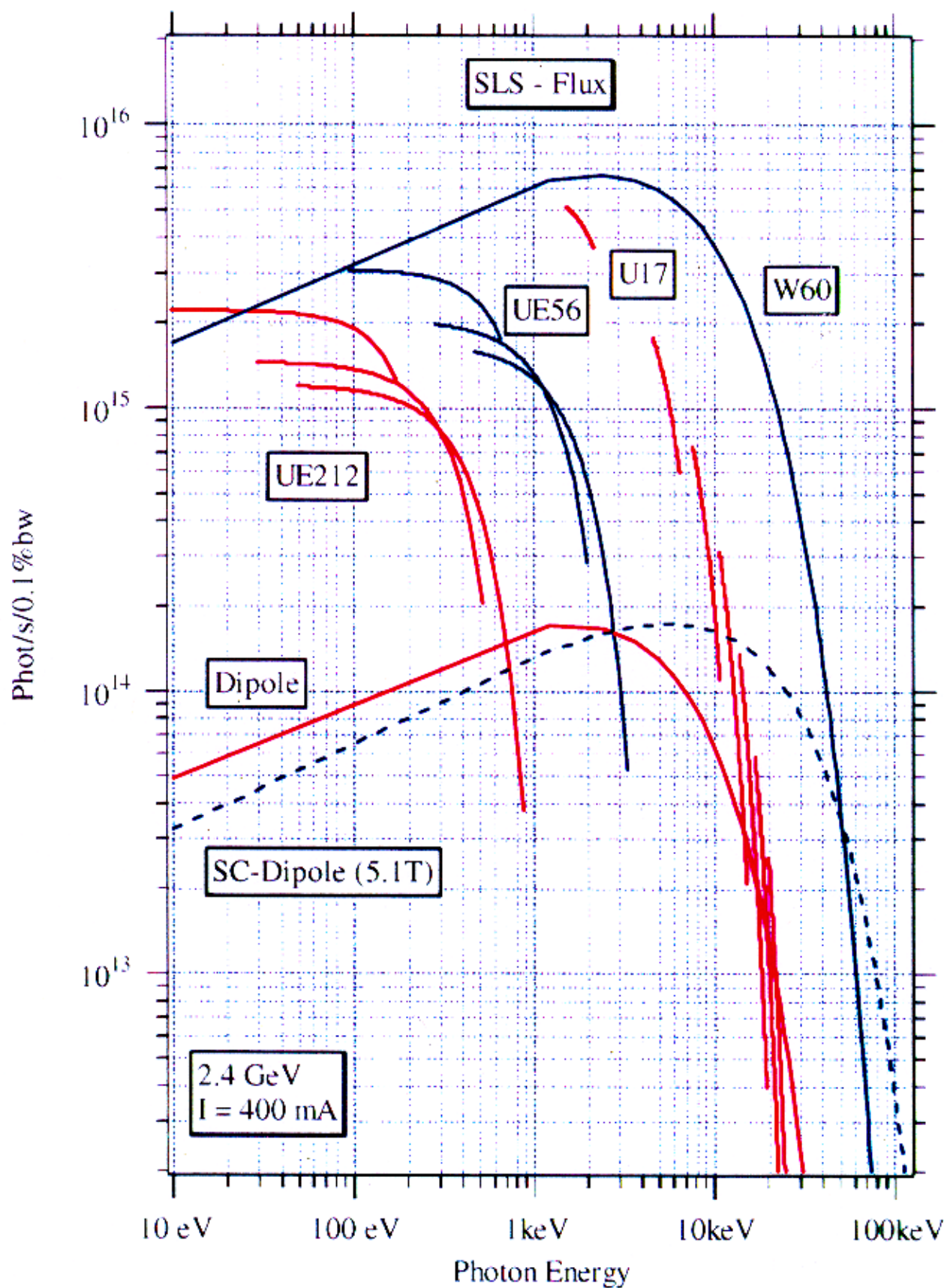
FUTURE LIGHT SOURCES

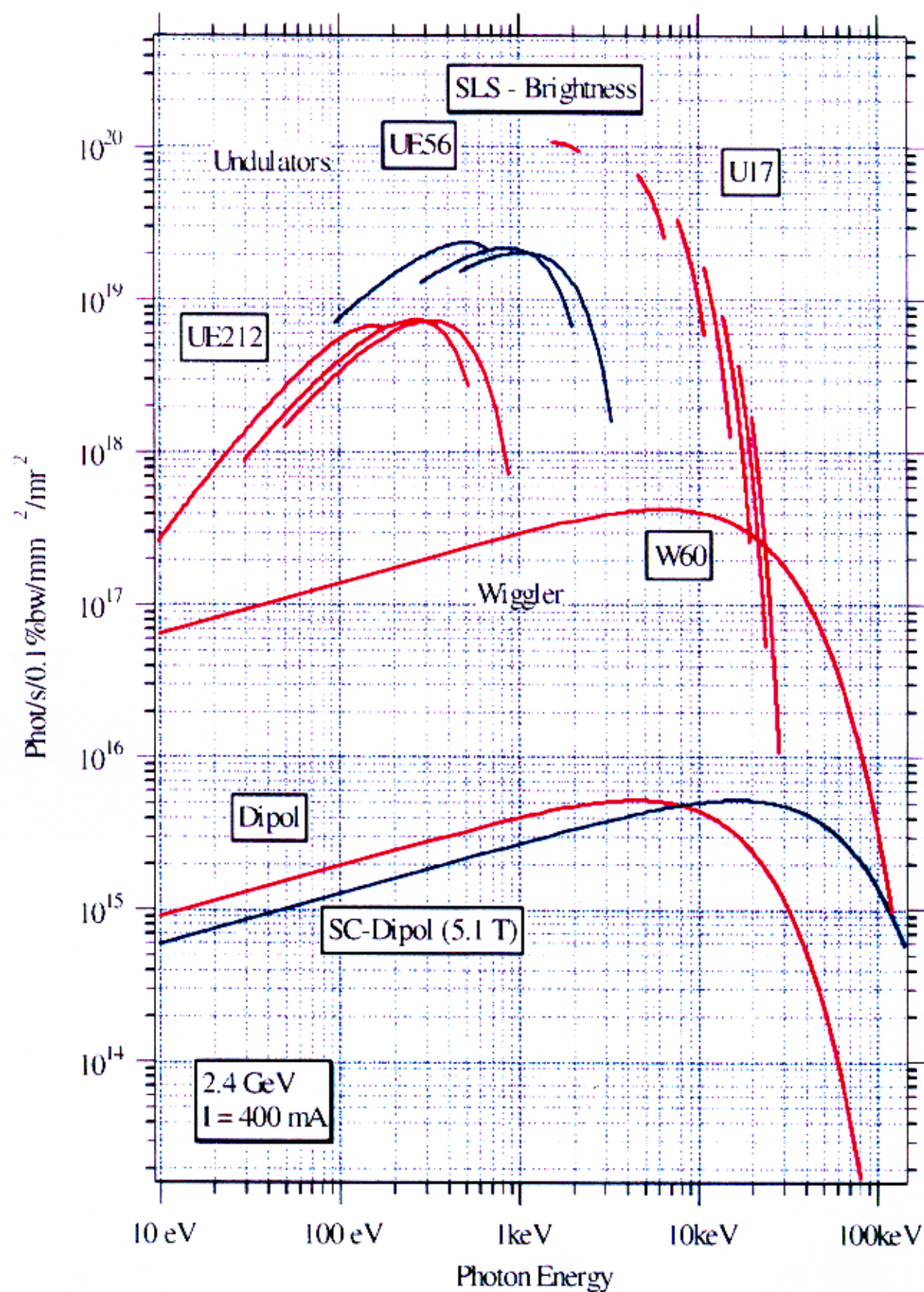
Argonne National Laboratory

April 6-9, 1999

Machine parameters

Energy	[GeV]	2.4
Circumference	[m]	288
RF frequency	[MHz]	500
Harmonic number		(2 5 x3x5 =) 480
Peak RF voltage	[MV]	2.6
Current	[mA]	400
Single bunch current	[mA]	10
Tunes		20.8 / 7.1
Natural chromaticity		-70/-20
Momentum compaction		0.0007
Critical photon energy	[keV]	5.4
Natural emittance	[nm·rad]	4.8
Radiation loss per turn	[keV]	512
Energy spread		$0.9 \cdot 10^{-3}$
Damping times (h/v/l)	[ms]	9 / 9 / 4.5
Bunch length	[mm]	3.5





SLS Material Science beamline : MS-wiggler W60

wiggler outside the vacuum
fixed gap ID-chambers

(APS chambers, extruded Al.)

ID-chamber (initial)
" (final)

: $g_{vac} = 8.0 \text{ mm or } 11.0 \text{ mm}$ } 2 chambers used
: $g_{vac} = 5.0 \text{ mm}$

energy range
figure of merit

: 5 - 40 keV ($E_c = 7.5 \text{ keV}$)
: max. horiz. flux density
min. total radiated power

current

: 400 mA

energy

: 2.4 GeV

spectral flux

: 2.0×10^{15} photons/s/0.1% bw (10 keV)
: 3.8×10^{13} photons/s/0.1% bw (40 keV)

total power

: 8.4 kWatt

wedge pole design
⊕ side magnets

period length

: 61.2 mm

periods

: 33

ID straight length

: 3.2 m

magnetic gap (initial):

$g_{mag} = 10.5 - 11.0 \text{ mm or } 13.5 - 14.0 \text{ mm}$

" "

(final): $g_{mag} = 7.5 \text{ mm}$

B_{max} (B_{eff})

: 1.97 T (1.69 T) (Tosca calc.)

K_{max} (K_{eff})

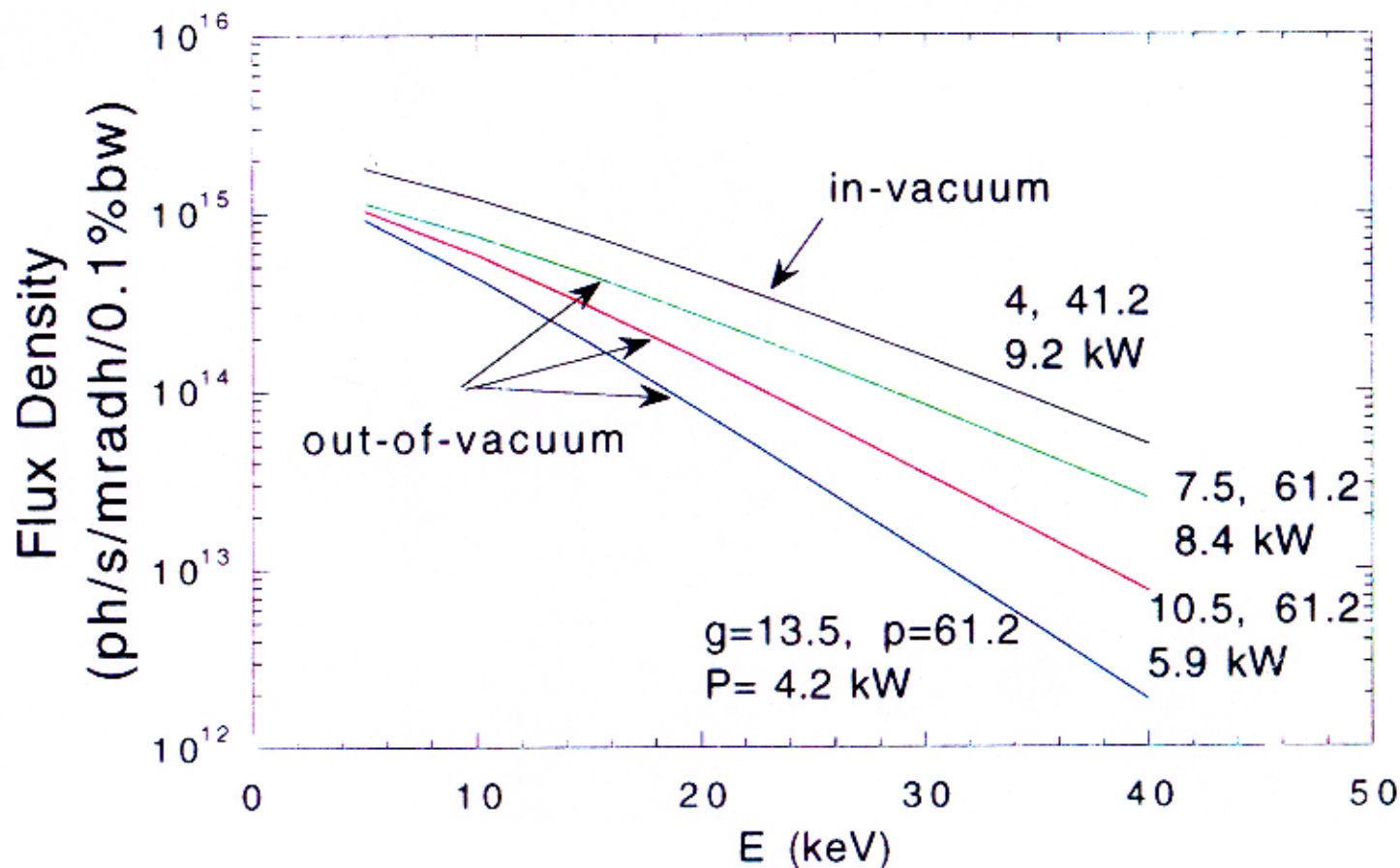
: 11.2 (9.7)

magnet material

: Neomax-48BH

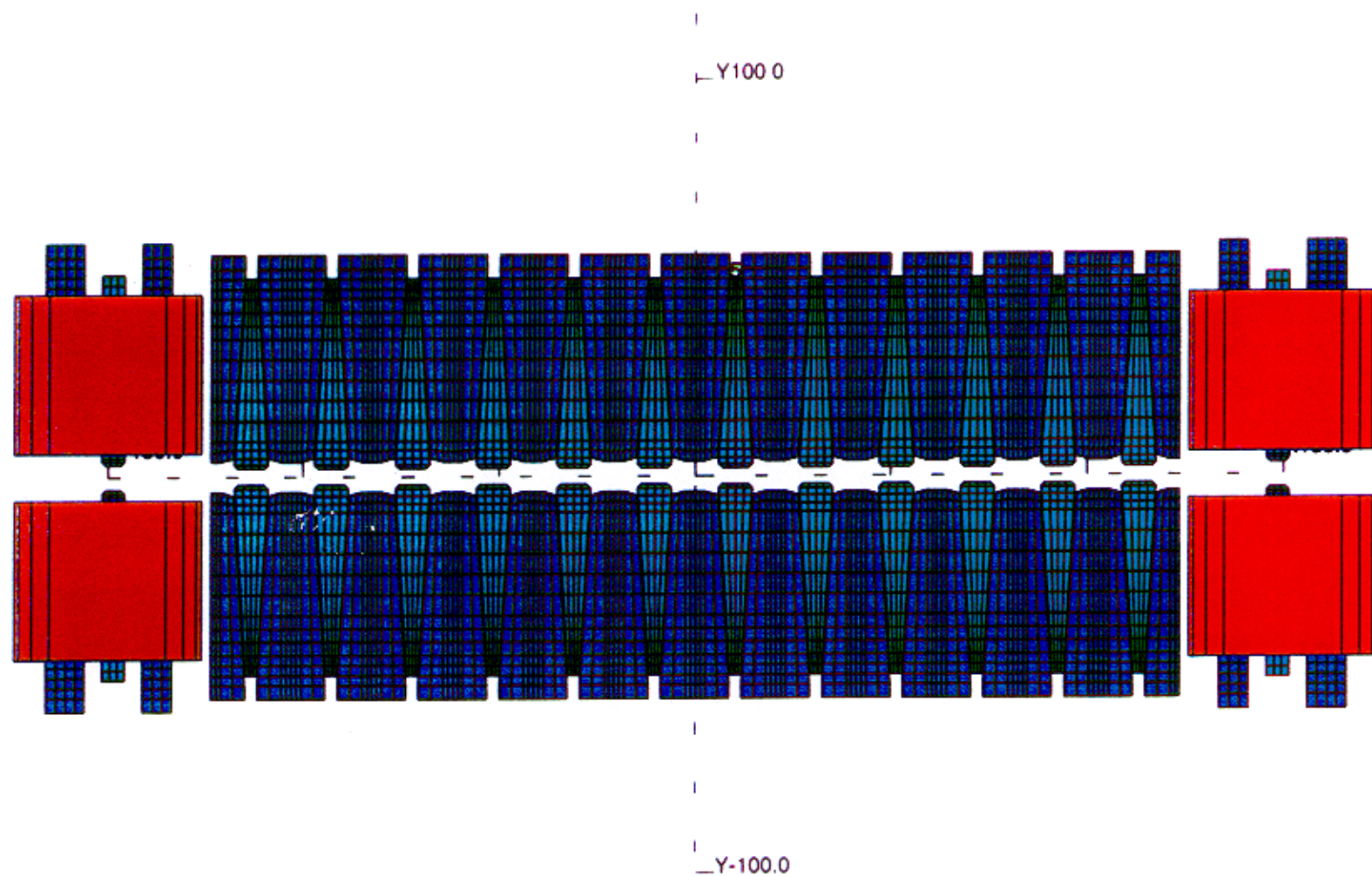
($B_r = 1.36 \text{ T}$, $H_{cj} = 14 \text{ kOe}$)

Mini-Gap Wiggler



SLS MS-wiggler W60

magnet design @ endpole design : similar to Bessy II hybrid undulators
↳ wedge pole design @ side magnets



UNITS

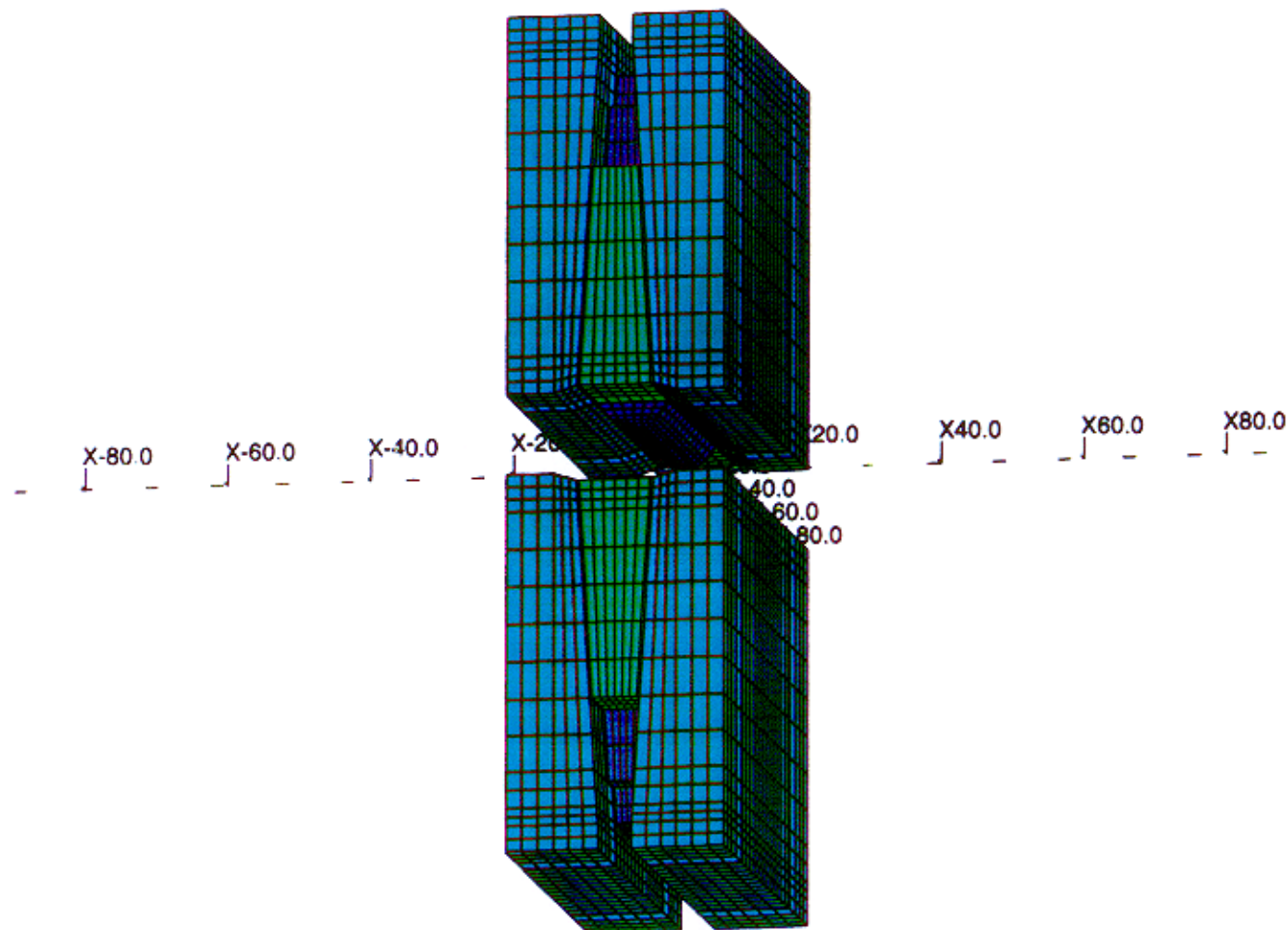
Length	: mm
Flux density	: gauss
Magnetic field	: A m
Scalar potential	: A
Vector potential	: Wb m
Conductivity	: S m
Current density	: A m ²
Power	: W
Force	: N
Energy	: J
Electric field	: V m

PROBLEM DATA

u41endsec8coil.toscab
TOSCA analysis (nl)
Magnetostatics
Case No. 1
139800 elements
149908 nodes
Shape funct. fields
Nodal coil fields

LOCAL COORDS.

Xlocal	= 0.0
Ylocal	= 0.0
Zlocal	= 0.0
Theta	= 0.0
Phi	= 0.0
Psi	= 0.0



UNITS

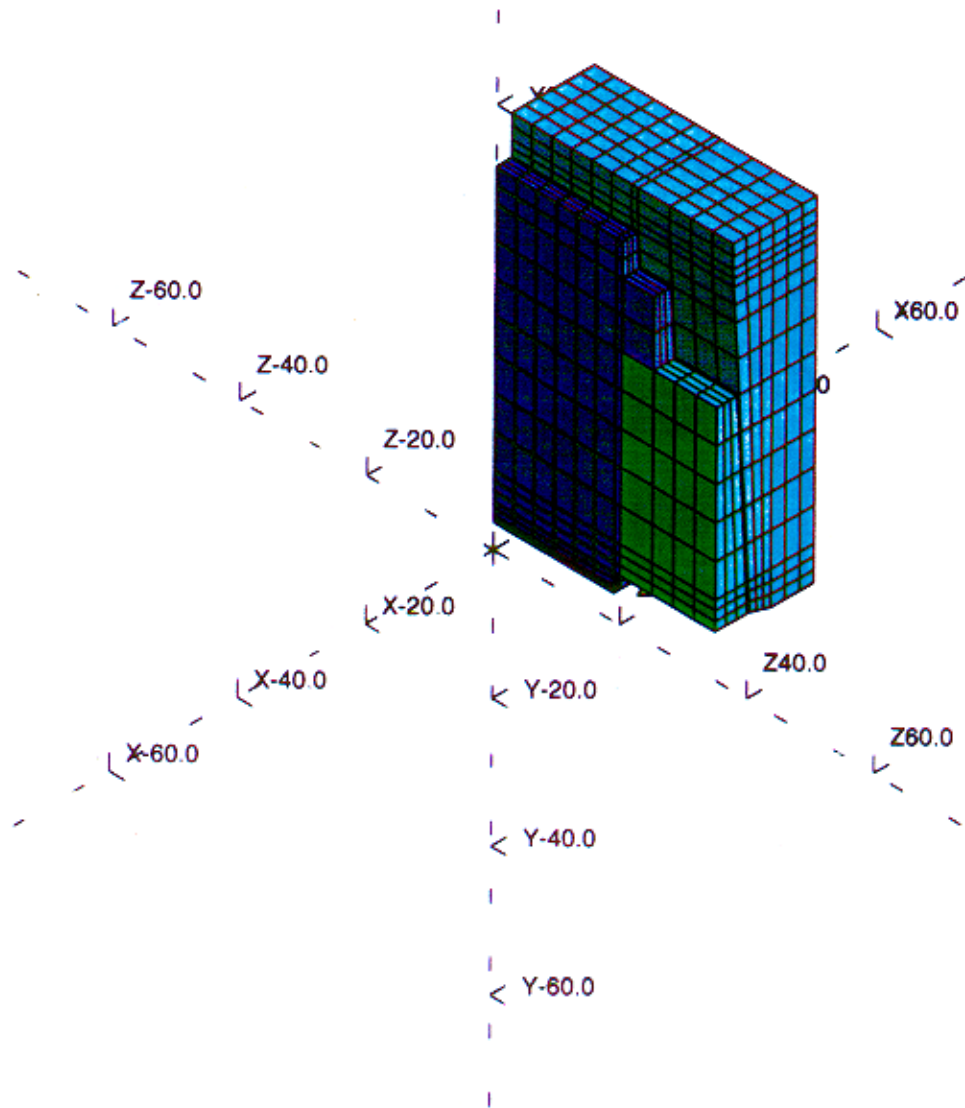
Length : mm
 Flux density : gauss
 Magnetic field : A m
 Scalar potential : A
 Vector potential : Wb m
 Conductivity : S m
 Current density : A m
 Power : W
 Force : N
 Energy : J
 Electric field : V m

PROBLEM DATA

u61quarter5.tocab
 TOSCA analysis (nl)
 Magnetostatics
 Case No 1
 23903 elements
 27212 nodes
 Nodal fields
 Nodal coil fields

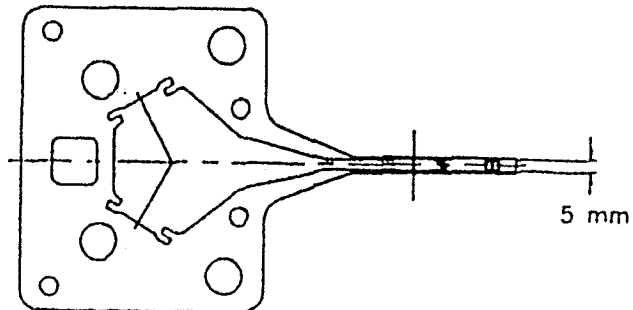
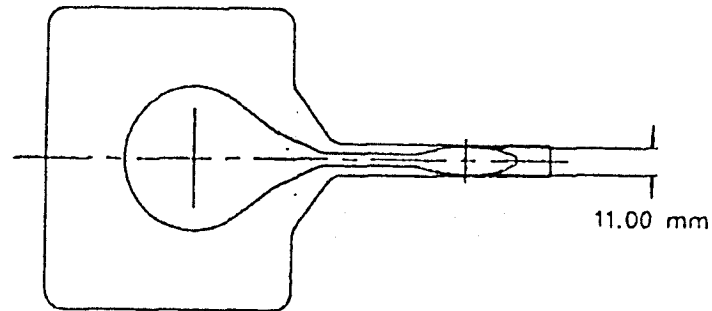
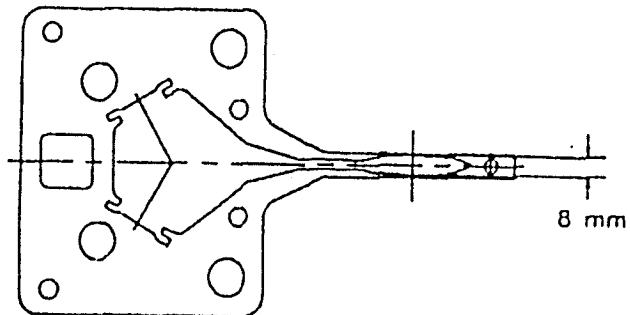
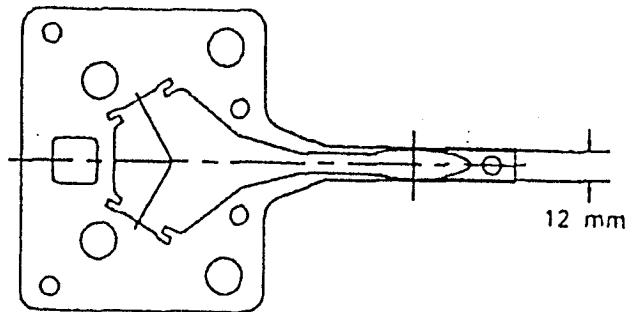
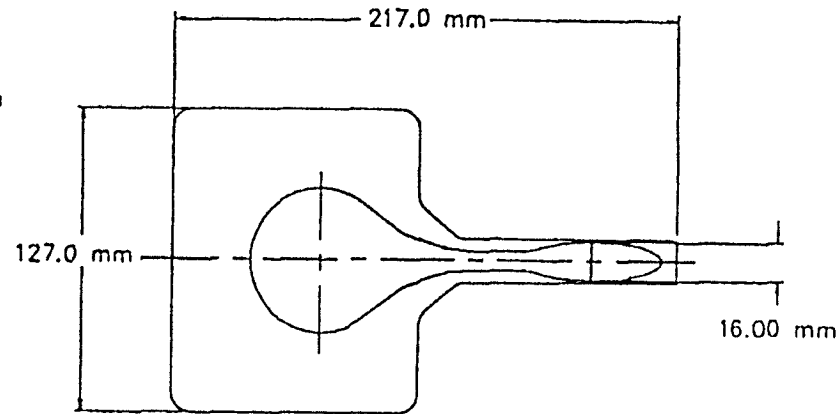
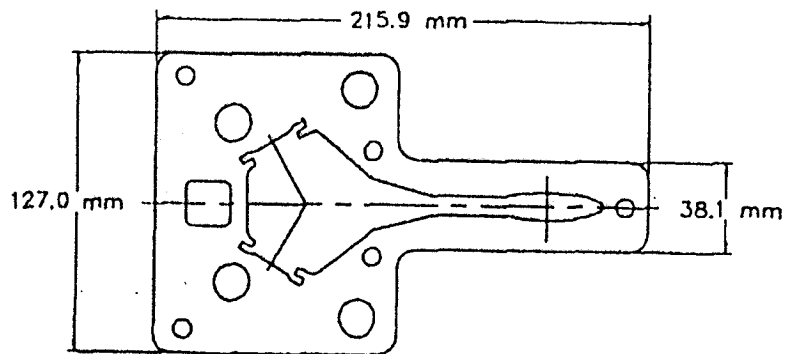
LOCAL COORDS

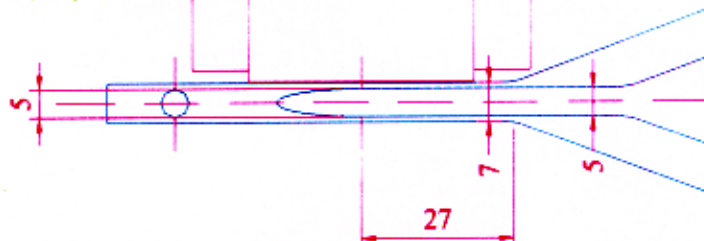
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 Zlocal = 0.0
 Theta = 0.0
 Phi = 0.0
 Psi = 0.0



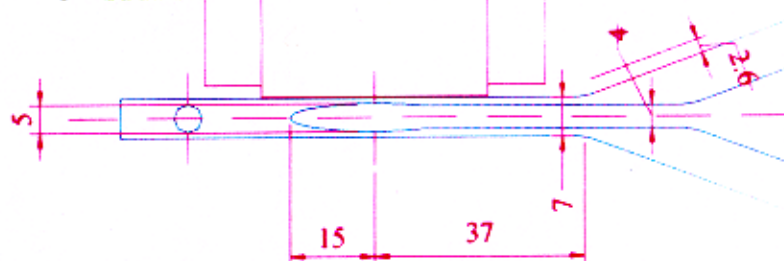
APS ID VACUUM CHAMBER FAMILY

(E. N. Trakhtenberg, E. Gluskin, S. Xu, Rev. Sci. Instr. 66
1995, 1809-1811)

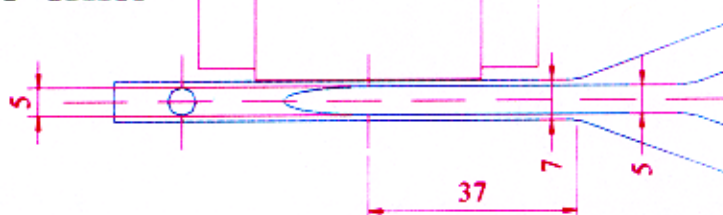


SLS ID Vacuum**Variations of the APS Small Gap Chamber****Var 1**
APS 5mm

max stress: 36 MPa
max. displ: 0.13 mm

Var 4
5 mm

max stress: 47 MPa
max. displ: 0.16 mm

Var 3
5 mm

max stress: 69 MPa
max. displ: 0.26 mm

Var 5
4 mm

max stress: 44 MPa
max. displ: 0.15 mm

Database: /usr2/people/wiegand/SLS/VACUUM/MS-WIGGLER/vacuumXX_3d.mfl

View : POST DETAIL VIEW 4

Task : Post Processing

Model: FEM - wiggler vcs var.4

Units : SI

Display : No stored Option

Model/Part Bin: LIB1 - WIGGLER VCS

Parent Part: Wiggler - VCS var.4

STRESS - vacuum pressure load, wiggler VCS var.4

RESULTS: 2- B.C. 1, STRESS_2, VACUUM PRESSURE LOAD

STRESS - VON MISES MIN: 1.64E+05 MAX: 4.67E+07

DEFORMATION: 1- B.C. 1, DISPLACEMENT_1, VACUUM PRESSURE L

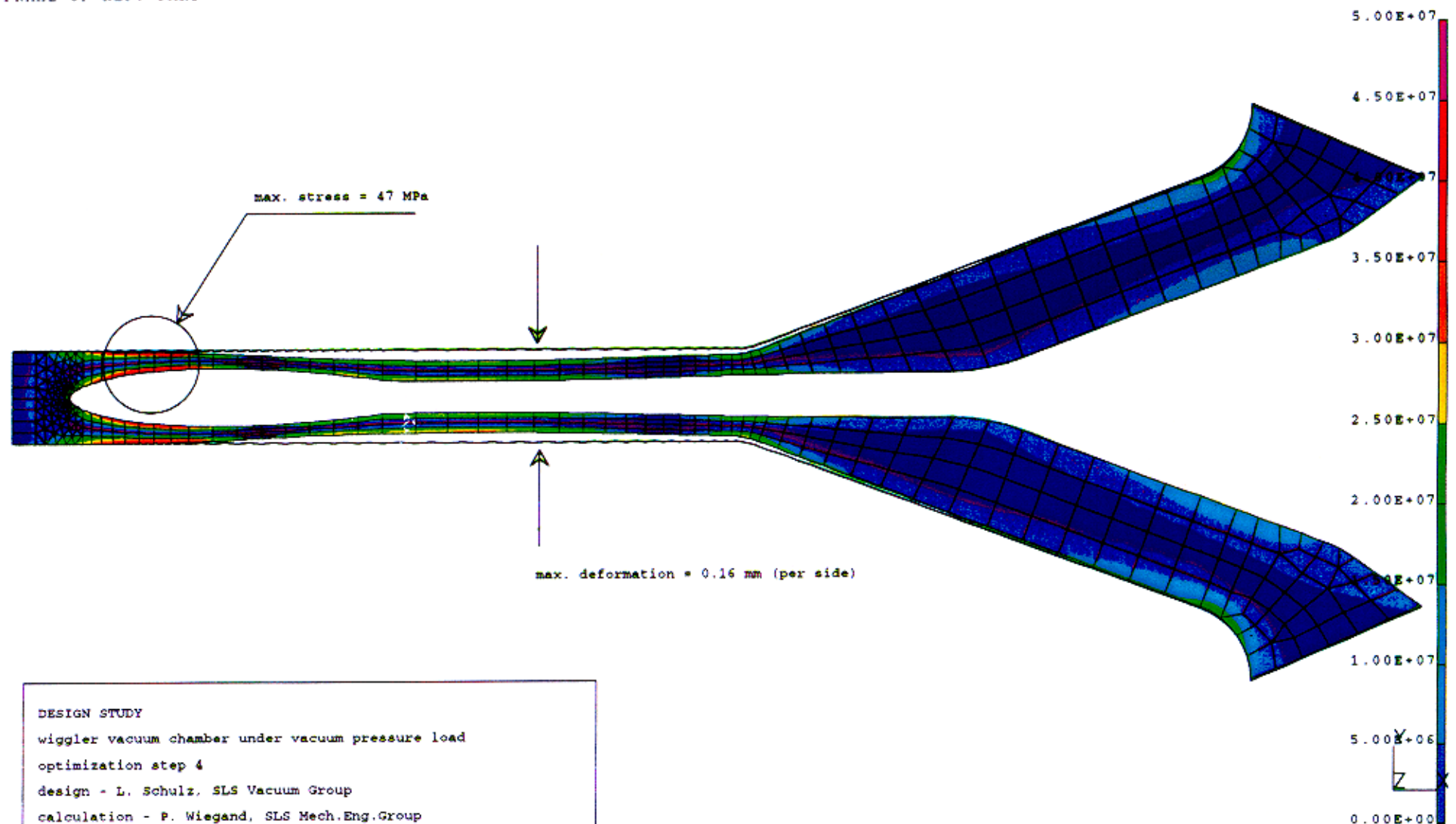
DISPLACEMENT - Y MIN: -1.59E-04 MAX: 1.59E-04

FRAME OF REF: PART

Stress in [Pa]

VALUE OPTION: ACTUAL

SHELL SURFACE: TOP



DESIGN STUDY

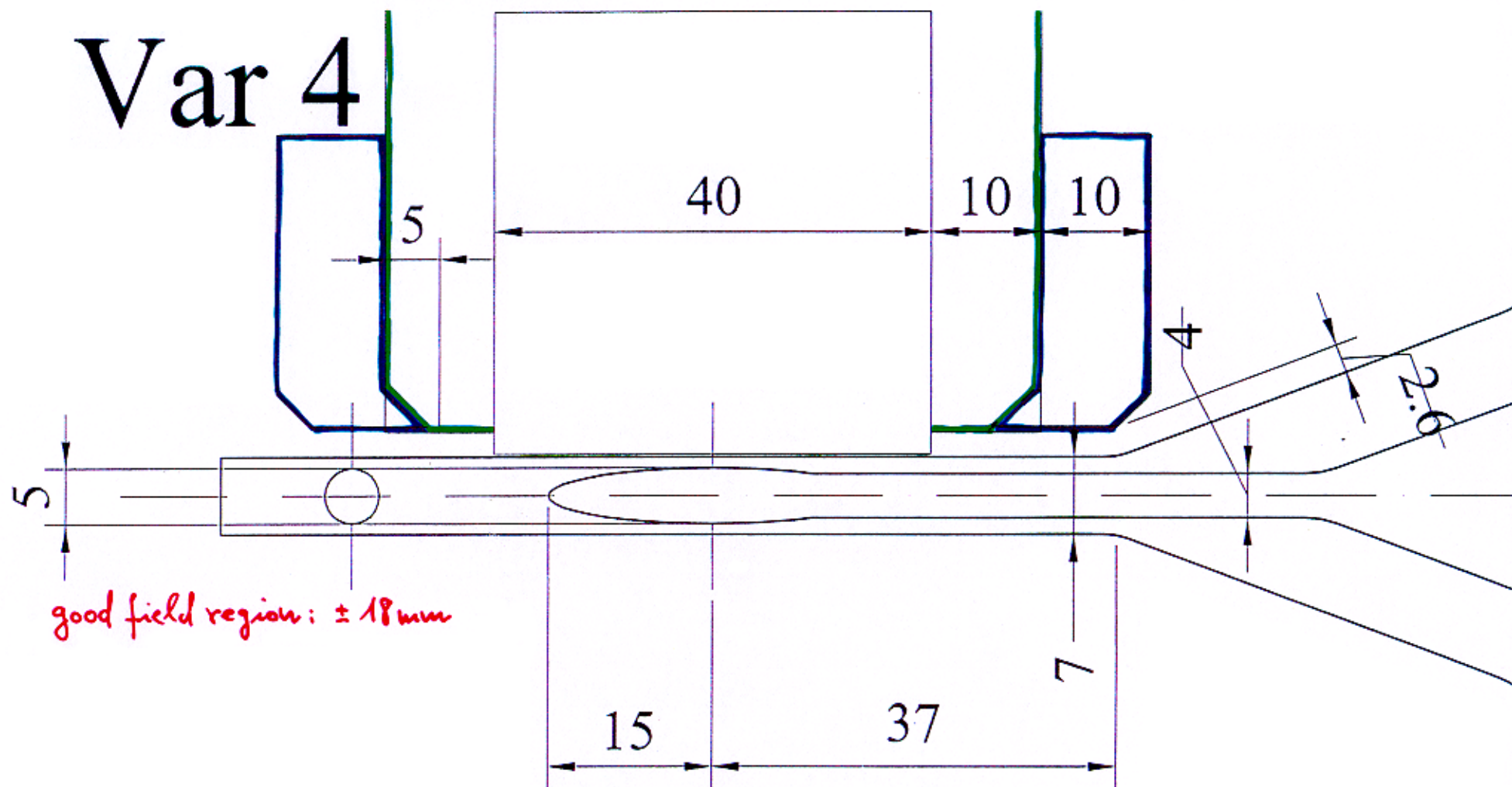
wiggler vacuum chamber under vacuum pressure load

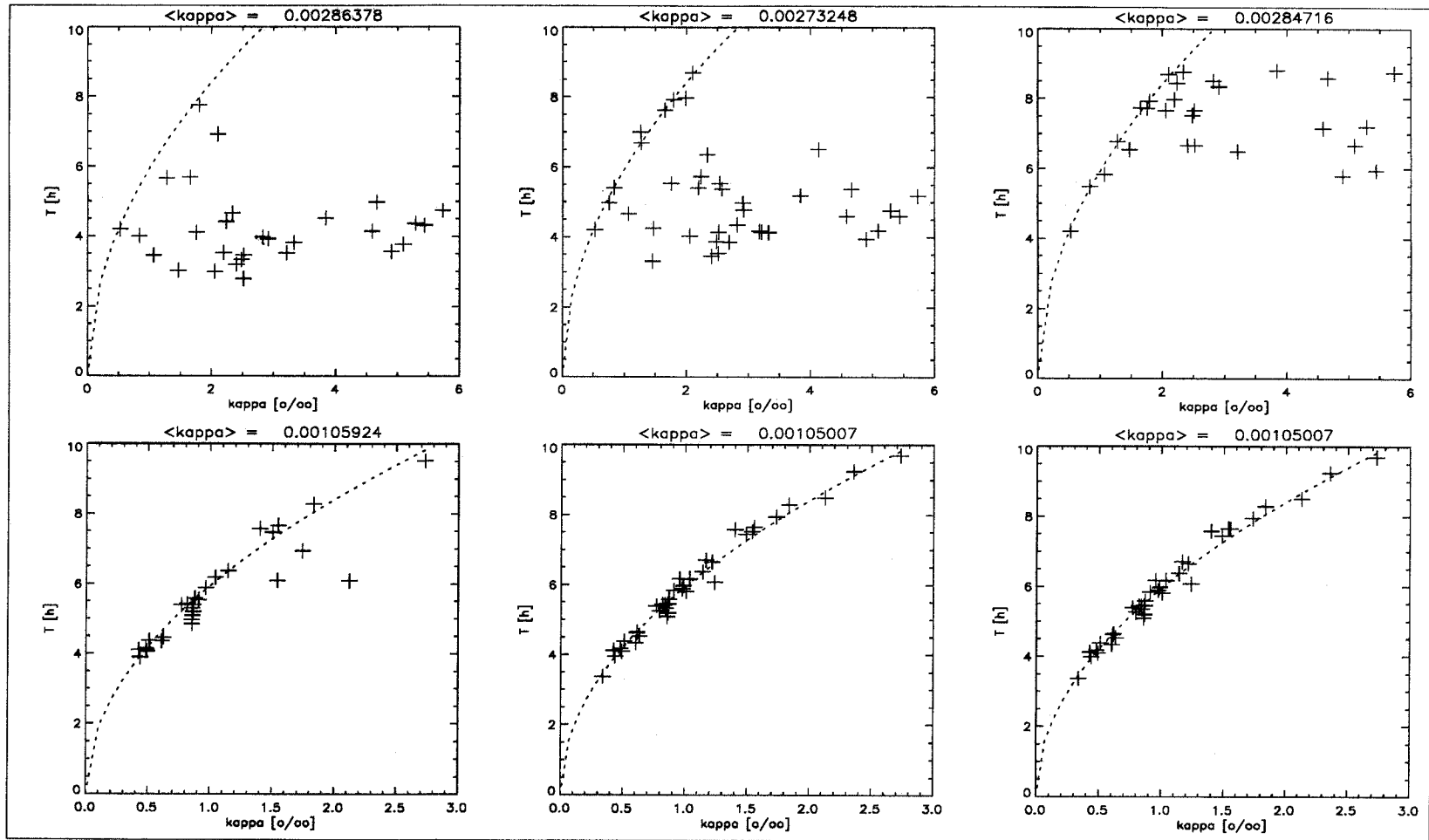
optimization step 4

design - L. Schulz, SLS Vacuum Group

calculation - P. Wiegand, SLS Mech.Eng.Group

Var 4





3 mm

4 mm

32 mm

Touschek lifetime vs. coupling for different full gap heights

Upper row without, lower row with coupling correction.

Dotted curve: $T \sim \sqrt{\kappa}$ for the error free lattice : points not
 $\uparrow$
 $\kappa = \epsilon_y / \epsilon_x$ lying on this curve indicate beam losses

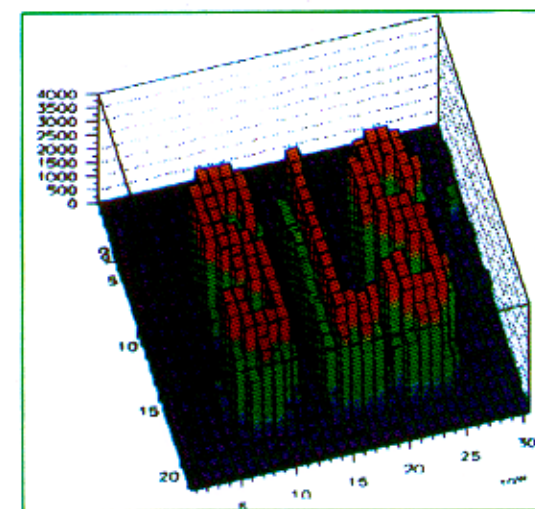
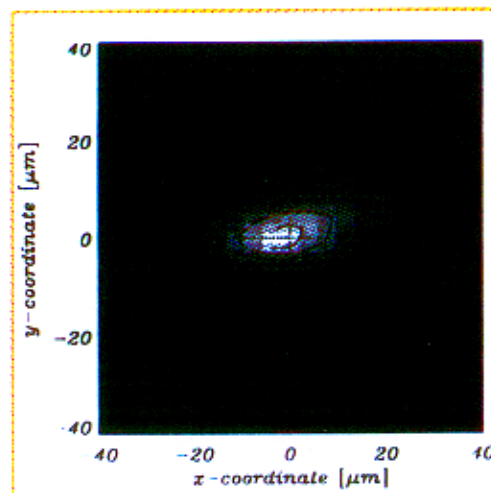
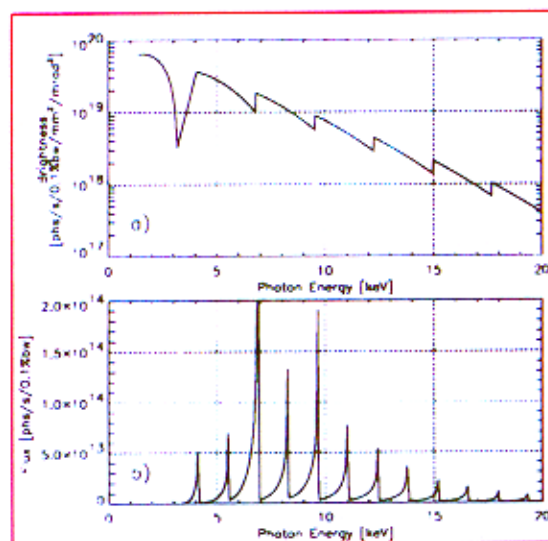
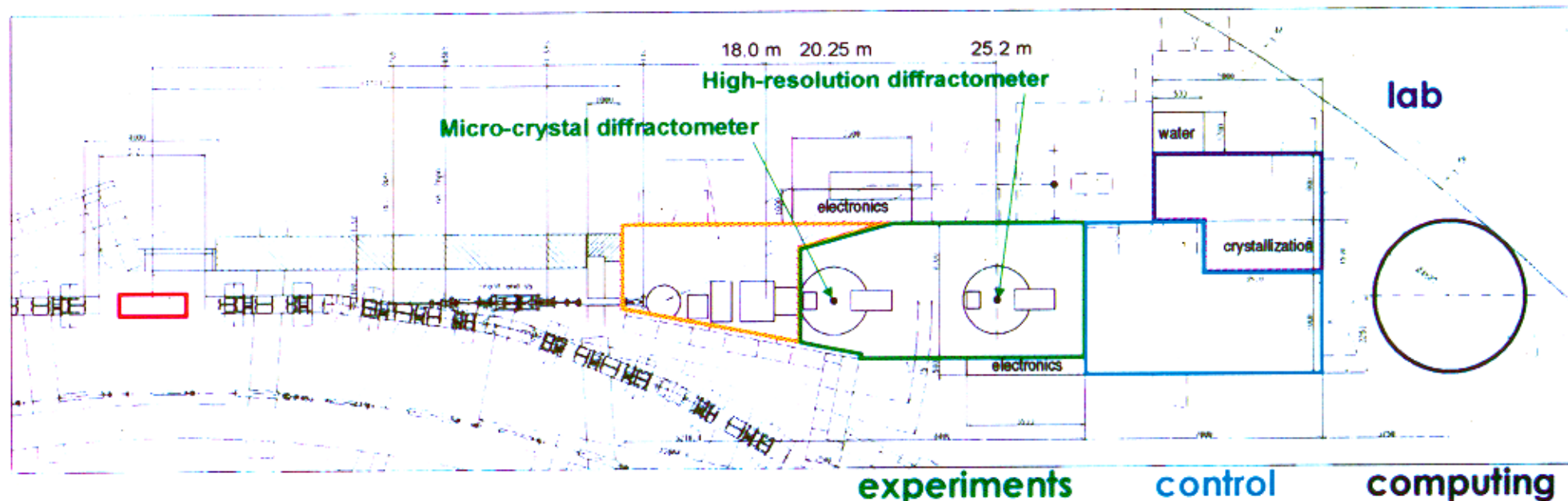
SLS PROTEIN CRYSTALLOGRAPHY BEAMLINE 6S



High Brightness In-Vacuum
Undulator Radiation

Decoupled, dynamically
focussing optics

Fast read-out, large area
Pixel Detector



Scientific Motivation

- micro-crystals
- large unit cell structures

but

$$I_{hkl} \approx \frac{V_x}{V_c} \times I_0$$

V_x : crystal volume
 V_c : unit cell volume



I_0 : primary beam
intensity



/ high flux
x (small area
low divergence)



HIGH BRIGHTNESS

- Multi-wavelength Anomalous Diffraction

SLS Advantages

- high brightness undulator radiation
- small source point (low β -section)
- short distance between source and optics
- tunability

Detector Requirements

Suitable detector for the SLS PX-beamline must be adapted to:

Main Beamline Properties

- Static protein crystallography of crystals with small physical dimensions as well as large unit cell structures
- Energy range: 5-17.5 keV
- Beam intensity: max 10^{13} X-rays/s on probe

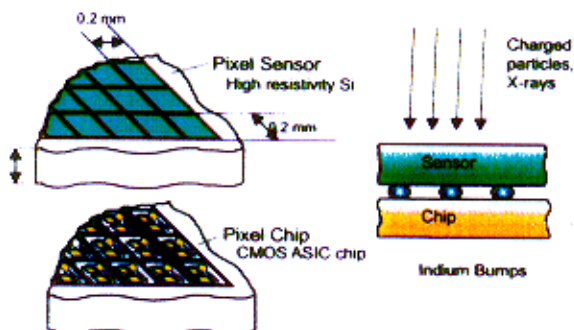
Needs of PX experiments

- Large area
- Fast read-out
- Low noise -> single photon counting detector

Pixel Detector Development

F1: CMS Collaboration: R. Horisberger et al, SLS: Christian Brönnimann

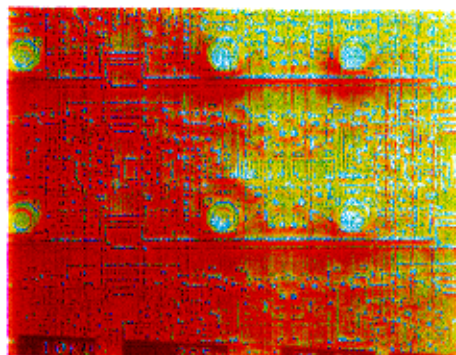
Principle



- Single photon counters
- Fast read-out, good energy and position resolution
- Architecture of pixel chip is dependent on application
- Choice of sensor material: (e.g. Si, GaAs)

Status

- Development of ASIC chips in CMOS technology
- Development of in-house bump bonding facility
- Goal: Assembly of large pixel detectors ($>10^6$ pixels)



REM-scan of 22x30 prototype pixel chip

Applications

- Tracking detectors for charged particles with excellent position resolution ($\sim 20\mu\text{m}$) and very fast readout (**particle physics**).
- Imaging detectors for X-rays (**Protein crystallography, powder diffraction, medical applications at SLS**)

Typical measurement at SLS/PX-beamline

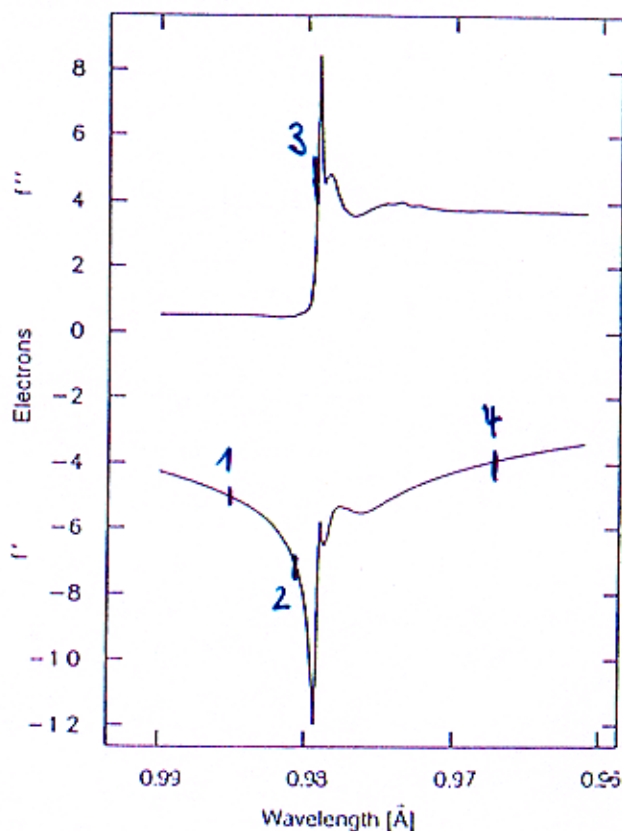


FIG. 2. Anomalous scattering factors near the absorption edge of selenium from a crystal of *E. coli* selenomethionyl thioredoxin. This spectrum was measured at SSRL beam line I-5 at high resolution. (Reproduced from Ref. 18, by permission of Oxford University Press.)

Se edge : 12.6 keV
Br edge : 13.5 keV } 90% of all measurements in this region

→ measurements at photon energies 1, 2, 3, 4
energies 1-3 within linewidth (0.5% FWHM): scan monochromator only
 $\Delta E(1-3) = 25 \text{ eV}$
energy 4: undulator gap change, $\Delta g = 50 \mu\text{m} \hat{=} \Delta E \approx 150 \text{ eV}$
 $\Delta E(1-4) = 150 \text{ eV}$

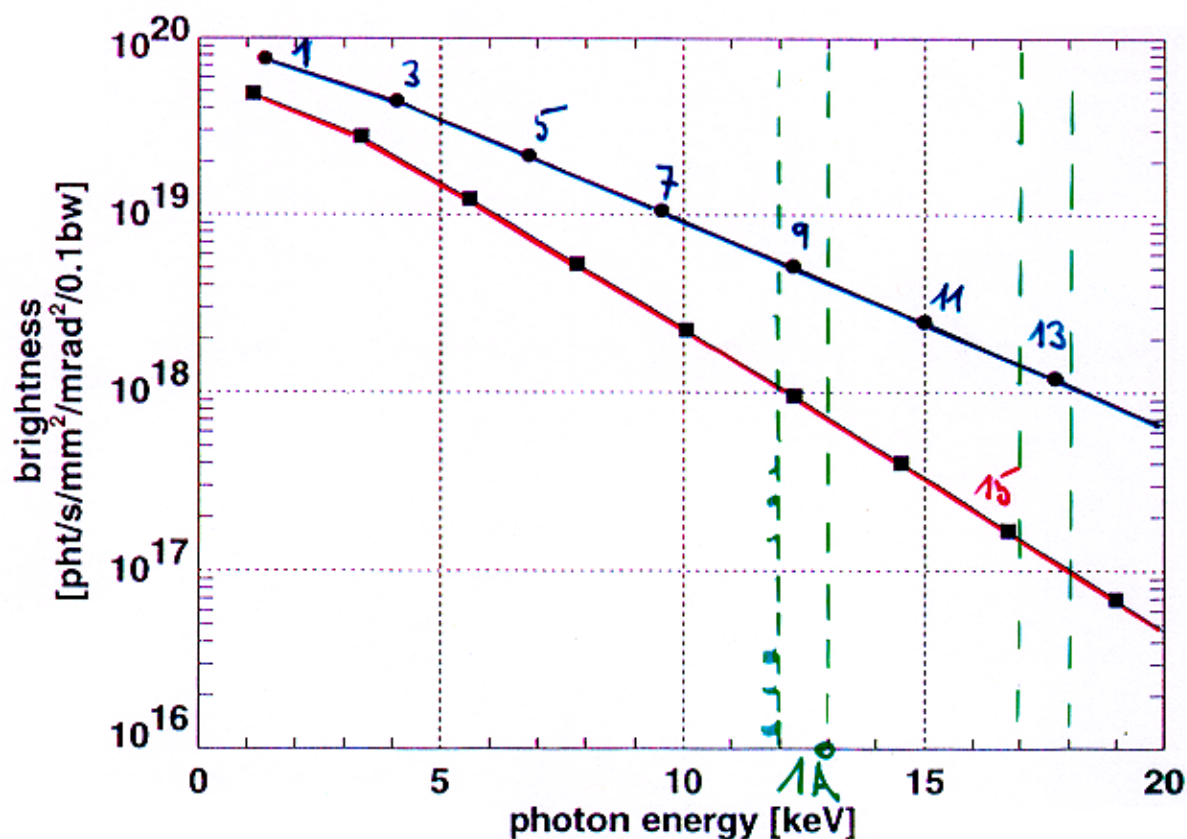
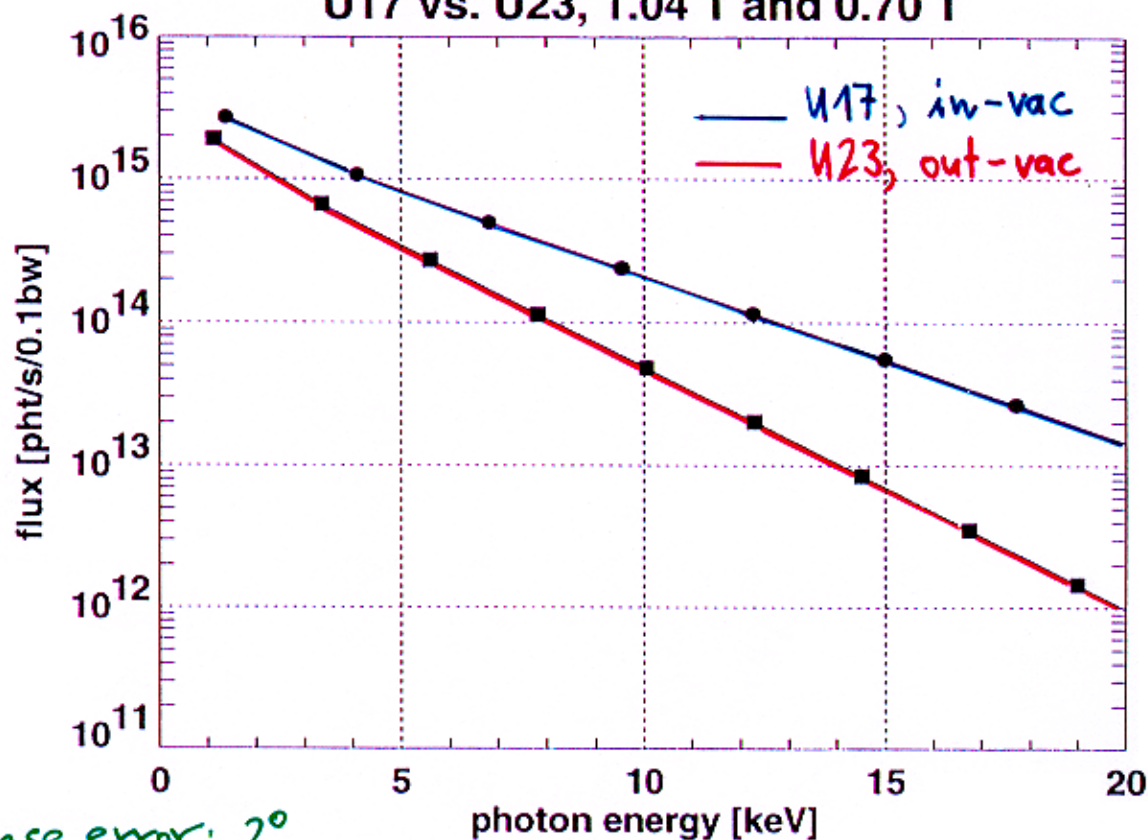
measurement cycle: energy 1 2 3 4 θ (rotate crystal)

50 measurements/setpoint	• → • → • → •	0°
	• ← • ← • ← •	5°
1 measurement takes ~ 1 sec with Pixel-Detector	↓ → •	10°
		⋮

↗ no backlash for the drive system;

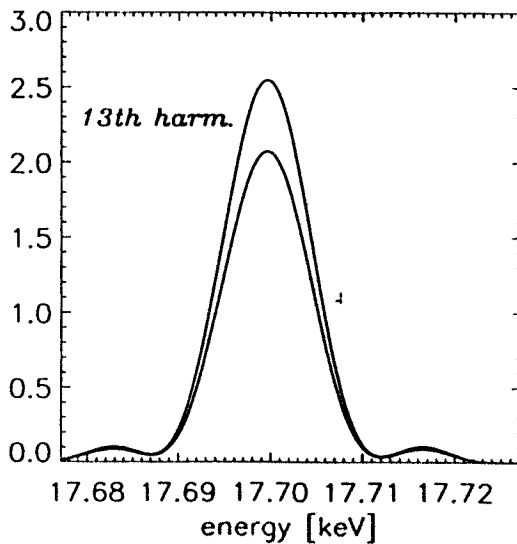
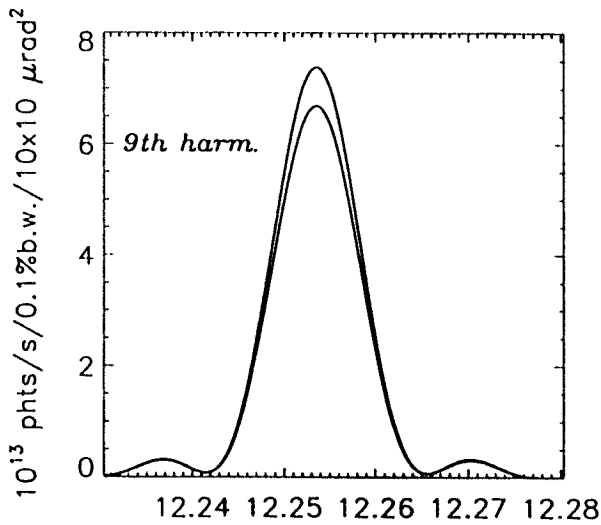
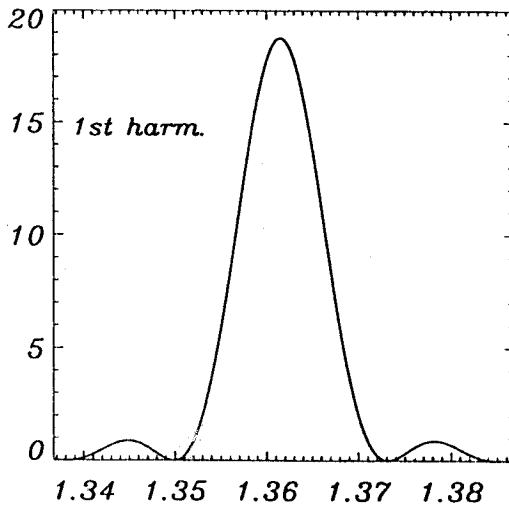
tuning range 12-14 keV $\hat{=} \Delta g = 4-5 \text{ mm}$

U17 vs. U23, 1.04 T and 0.70 T



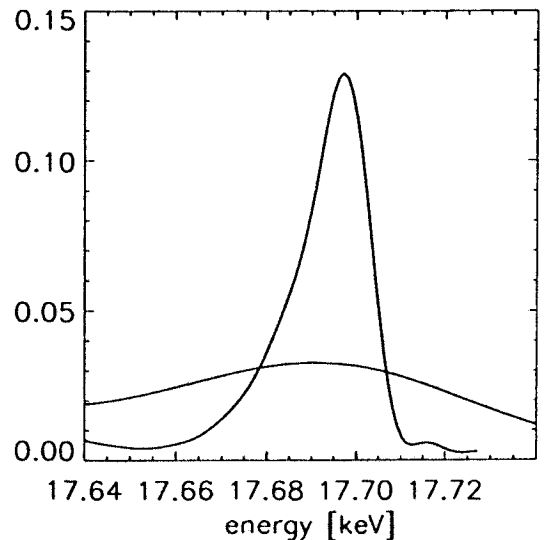
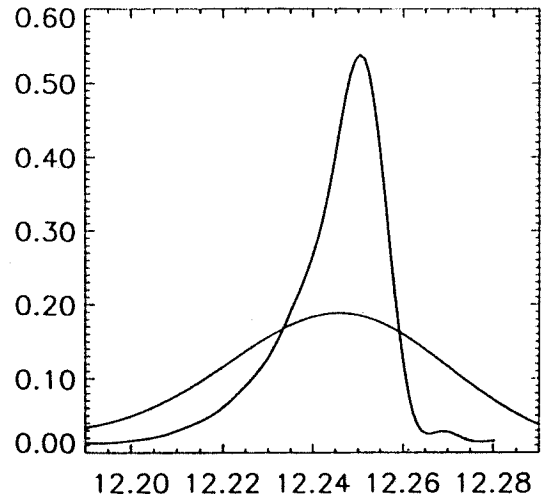
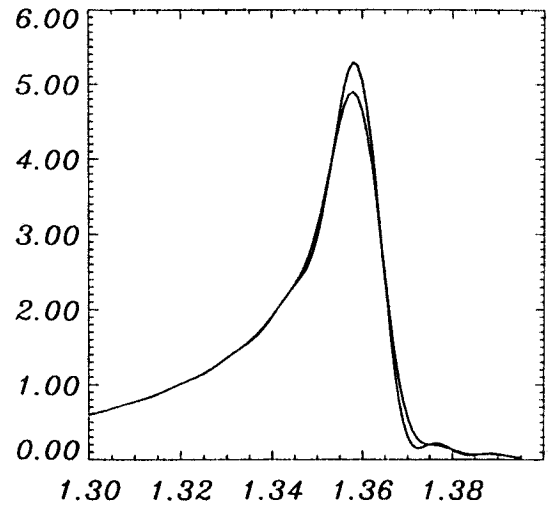
PX-undulator

single electron spectra



real beam

spectra including emittance and energy spread



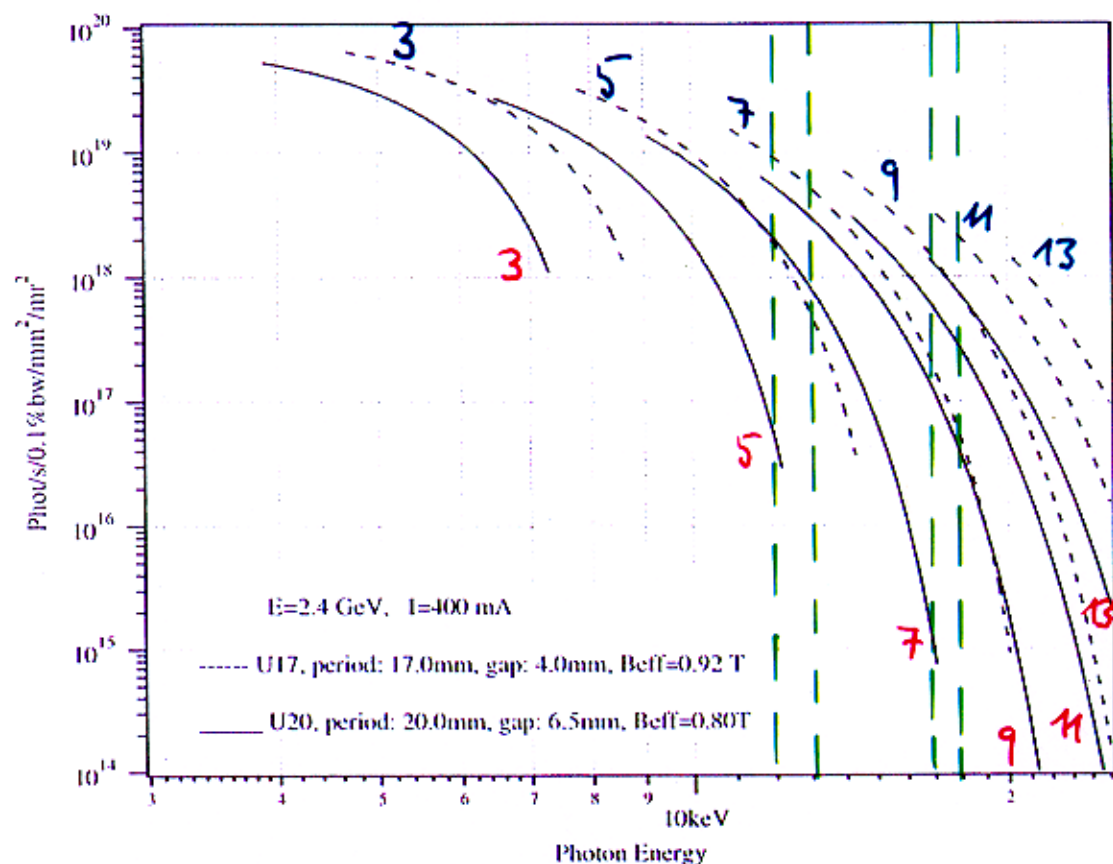
Distance: 10m, $I = 400\text{mA}$, pinhole $0.1 \times 0.1\text{mm}^2$

Magnet Materials

Ⓐ	$\text{Sm}_2\text{Co}_{17}$	$B_r = 1.05\text{T}$ $H_{cJ} \approx 1850\text{ kA/m}$	Vacomax 225 HR
Ⓑ	$\text{Nd}_2\text{Fe}_{14}\text{B}$	$B_r = 1.15\text{T}$ $H_{cJ} \approx 2300\text{ kA/m}$ $H_{cJ} \approx 1980\text{ kA/m}$	Neomax-32 EH, Vacodym 400 HR Neomax-33 UH
Ⓒ	$\text{Nd}_2\text{Fe}_{14}\text{B}$	$B_r = 1.21\text{T}$ $H_{cJ} \approx 1950\text{ kA/m}$	Neomax-35 EH, Vacodym 396 HR
Ⓓ	$\text{Nd}_2\text{Fe}_{14}\text{B}$	$B_r = 1.26\text{T}$ $H_{cJ} \approx 1600\text{ kA/m}$	Neomax-39 SH, Vacodym 383 HR

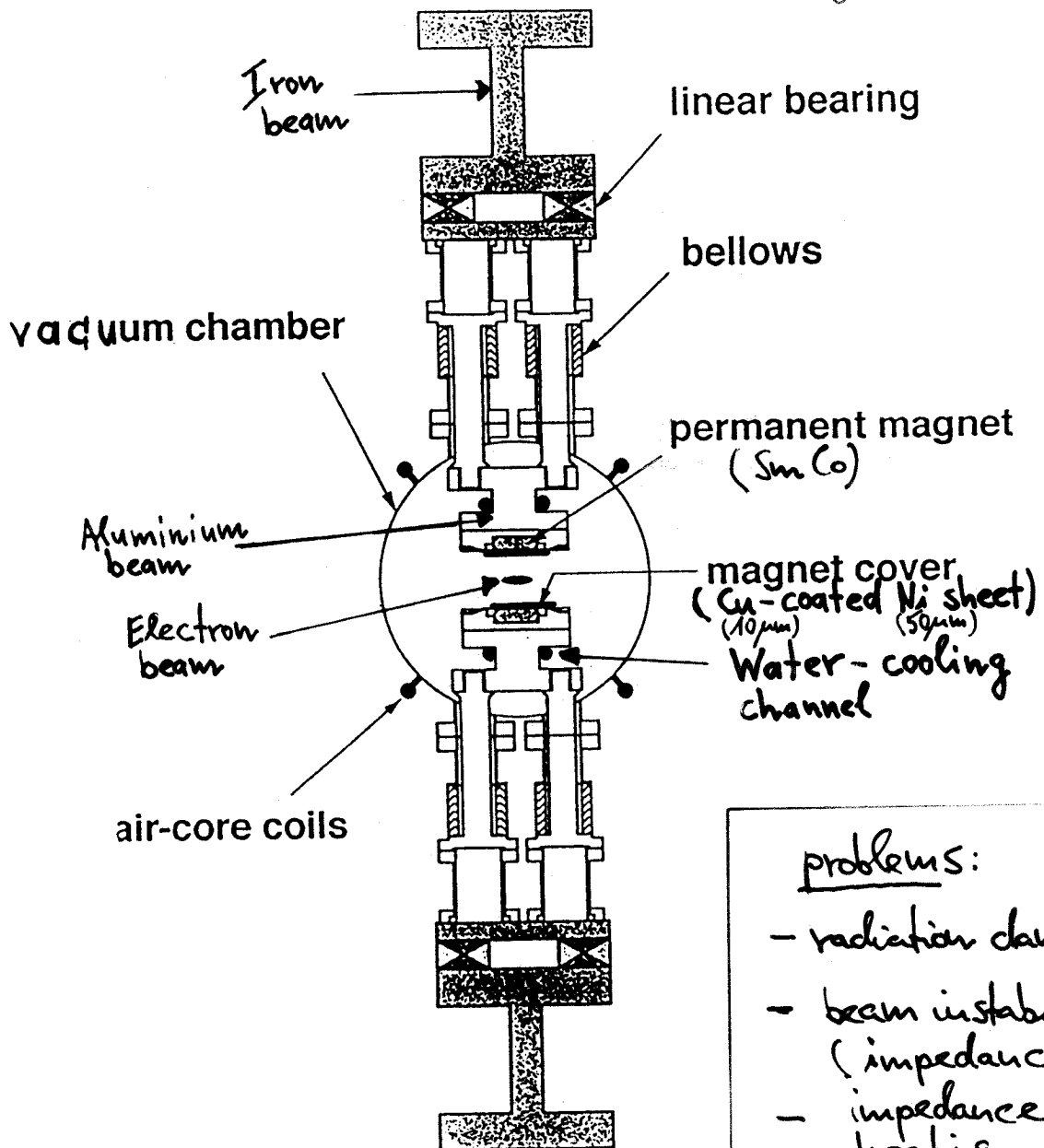
in-vacuum undulator : materials Ⓐ, Ⓑ

out-vacuum undulator : materials Ⓐ - Ⓓ



U20 : out-vacuum option, 4mm APS chamber
 (has to be developed)
 NdFeB magnets, $B_r \approx 1.26$ T

In-Vacuum Undulators (risky technology!) g = 4.0 mm



problems:

- radiation damage
- beam instabilities (impedance)
- impedance heating

1.) Bessy "in-vacuum" undulator (first in-vac device, medium vacuum)

2.) SPring-8 (ultra-high vacuum)

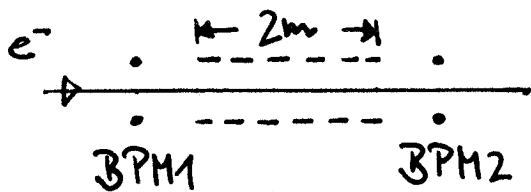
→ SPring-8 / NSLS

→ SPring-8 / ESRF

→ ESRF → ESRF / PSI (collab.)

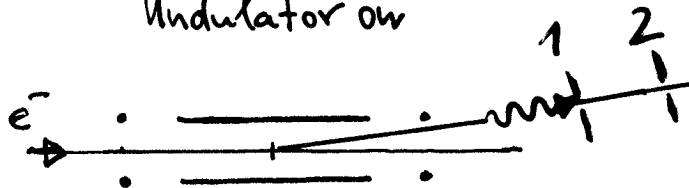
Alignment

"Undulator off"



"straight line" reference:
electron beam

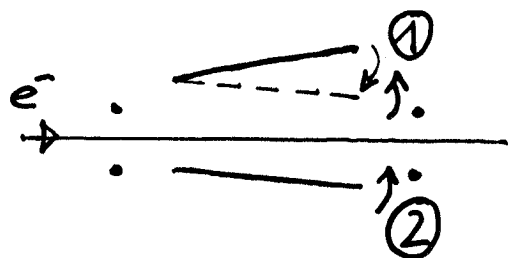
"Undulator on"



"straight line" reference:
photon beam

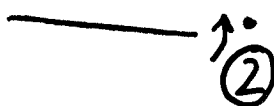
In general there is :
(neglect bending/sag)

gap taper
" tilt
" offset } $\Rightarrow$ measure $\oplus$ correct



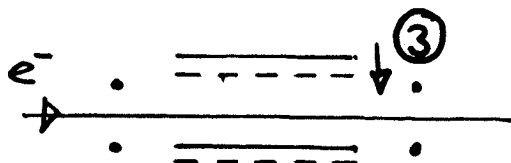
correct: gap taper
($\leq 5 \mu\text{m}$)

monitor:
abs. lin. Encoder



correct: gap tilt

tilt-sensor?



correct: gap offset

lifetime $\times$
bremsstrahlung

Drive system

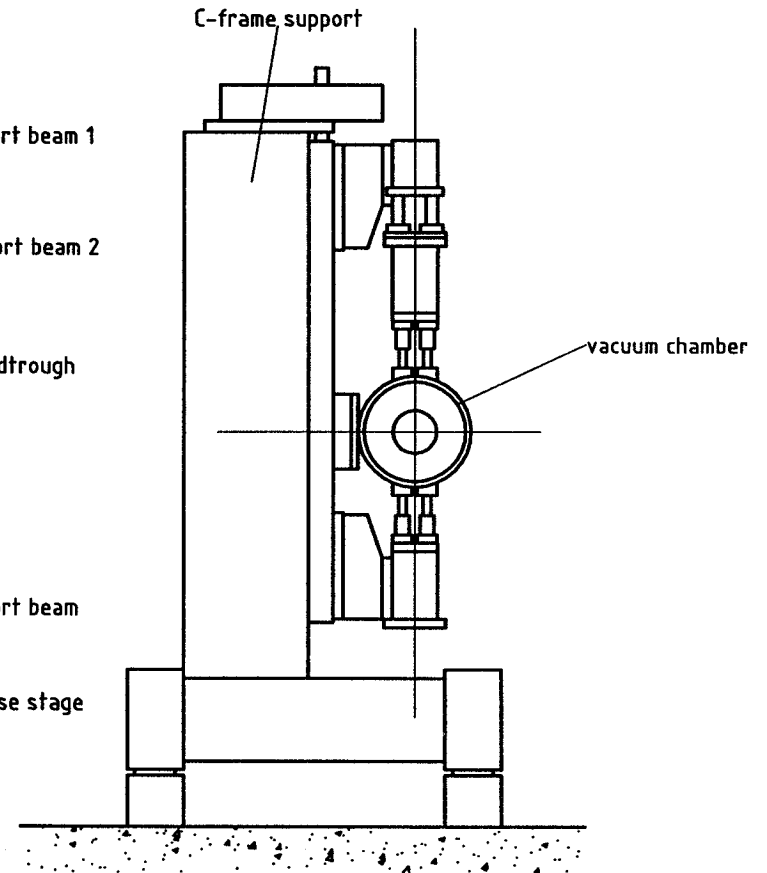
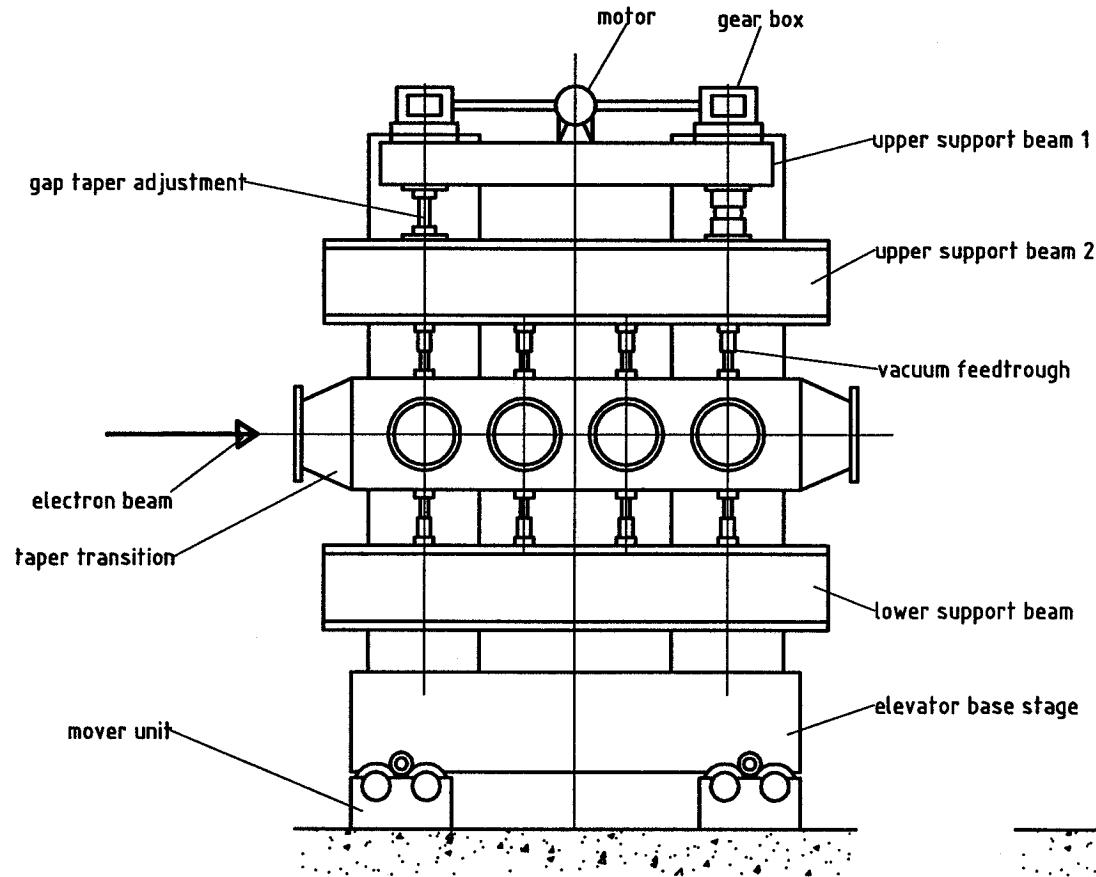
coarse gap-adjustment :
fine " " :

switch undulator on/off
correct gap taper

fine adjustment undulator:
support

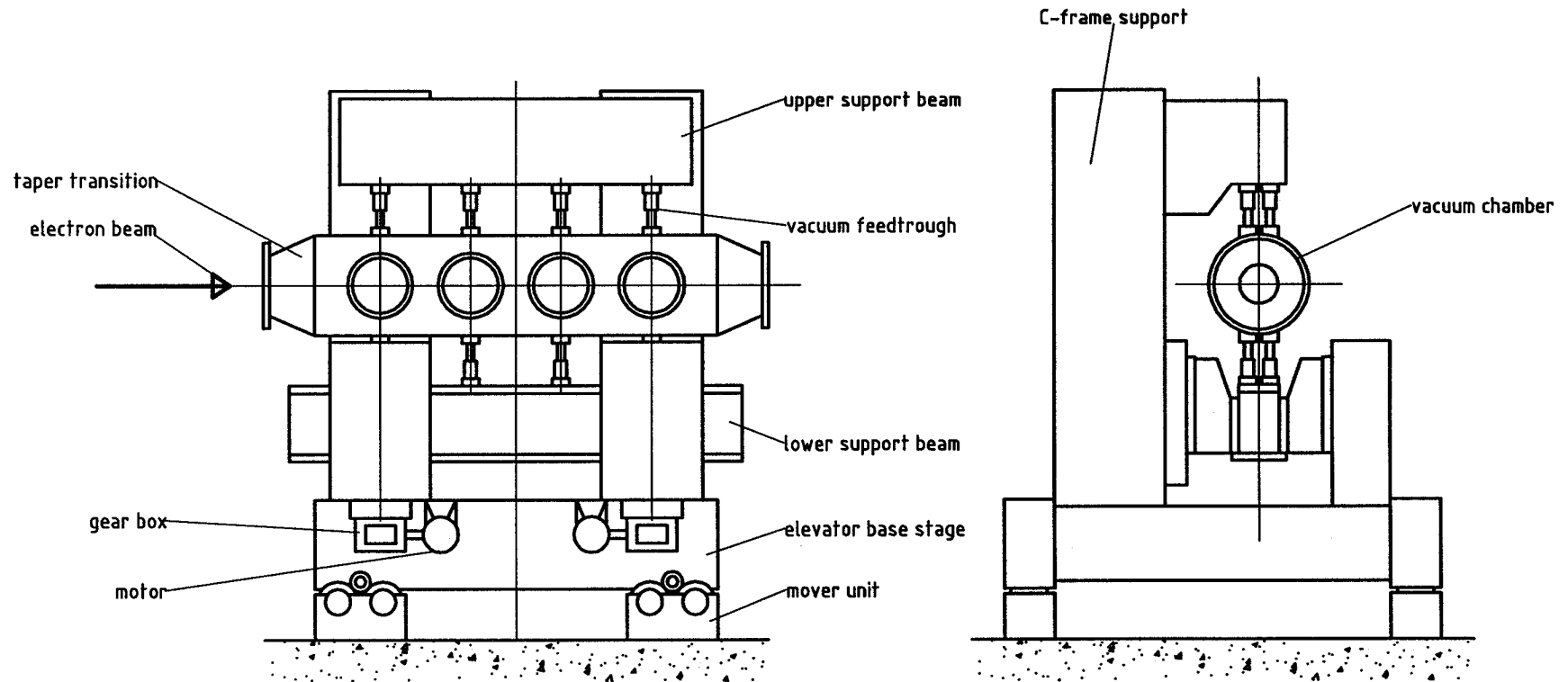
correct gap tilt
" " offset

In - Vacuum Undulator Support and Drive System



Proj.				Subnummer		Bauelement / Merkmale			
1	2	3	4	5	6	7	8	9	10
1	2	3	4	5	6	7	8	9	10
1	2	3	4	5	6	7	8	9	10
Auftrag SLS						Erstellt durch			
Projektgruppe						Geprüft von			
Vakuum Undulator Var. I						Gezeichnet von			
						Zusammengefasst von			
FEI						Uebersichtsskizze			
						2-30040.36.036			

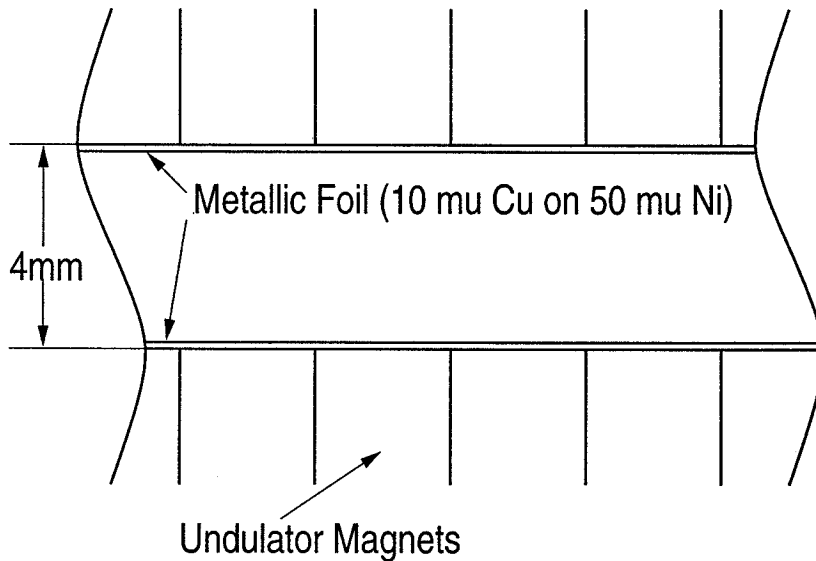
In - Vacuum Undulator Support and Drive System



Pos.		Benennung		Zusammenfassung / Merkmale				Material	
1		2		3		4		5	
6		7		8		9		10	
11		12		13		14		15	
16		17		18		19		20	
21		22		23		24		25	
26		27		28		29		30	
31		32		33		34		35	
36		37		38		39		40	
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251		252		253		254		255	
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271		272		273		274		275	
276		277		278		279		280	
281		282		283		284		285	
286		287		288		289		290	
291		292		293		294		295	
296		297		298		299		300	
301		302		303		304		305	
306		307		308		309		31	

Resistive Impedances in the SLS In Vacuum Undulator

Structure Layout:



Total undulator length: 2m

Above 43 MHz resistance dominated by
Cu layer, 10-43 MHz by Ni layer

Assuming constant gap height
(reality: periodic variation by app. 0.2 mm)

Results

	Undulator	Std. ring chamber
Z/n	1 mOhm	39 mOhm
Max. transverse Impedance (f. tune 0.44)		
	3.4 MOhm/m	1.3 MOhm/m
Corr. CB instability growth rate		
	0.55 ms	1.5 ms
Conductive Losses:		
100% fill/0.4A	11 W/m	3.1 W/m
4 nC single bunch	0.5 W/m	0.2 W/m

Missing:

Behaviour <10 MHz (Global Layout!)

Gap height variations
(Z/n , long range wakes)